

IAP6 Rec'd PCT/PTO 22 NOV 2005

INFORMATION DISCLOSURE STATEMENT

Applicant	:	Hada et al.
App. No	:	Unknown
Filed	:	Herewith
For	:	RESIN FOR PHOTORESIST COMPOSITION, PHOTOESSIT COMPOSITION AND METHOD FOR FORMING RESIST PATTERN
Examiner	:	Unknown
Art Unit	:	Unknown

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 18 references to be considered by the Examiner. Also enclosed are 14 foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement. Please note the relevance of JP 7-234511, JP 11-012326, JP 2001-002735, JP 05-346668, JP 09-073173, JP 09-090637, JP 10-161313 , JP 2002-311587 and JP 10-319595 is that they are cited in the subject specification and/or the International Search Report and Written Opinion from PCT priority application no. PCT/JP2004/008004. The relevance of JP 2000-3211771 is that is it cited in the International Search Report and Written Opinion from PCT priority application no. PCT/JP2004/008004. Please also note that US 5,968,713 corresponds to JP 09-73173 and JP 09-90637 and US 6,656,659 corresponds to JP 10-319595.

This Information Disclosure Statement is being filed within three months of the filing date, and no fee is required.

10/557694

Appl. No. : Unknown
Filed : Herewith

Docket No. SHIGA7.033APC

Customer No. 20,995

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The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 22 Nov. 2005

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(Multiple sheets used when necessary)</i>	Application No.	Unknown	
	Filing Date	Herewith 20/557694	
	First Named Inventor	Hada, Hideo	
	Art Unit	Unknown	
SHEET 1 OF 1		Examiner	Unknown
		Attorney Docket No.	SHIGA7.033APC

U.S. PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1	US 2002/0150834 A1	10-17-2002	Yamamoto et al.	
	2	6,596,458 B1	07-22-2003	Sato et al.	
	3	5,968,713	10-19-1999	Nozaki et al.	
	4	6,656,659 B1	12-02-2003	Nozaki et al.	

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
	5	JP 7-234511	09-05-1995			
	6	EP 0 663 616 B1	10-30-2002	Fujitsu Ltd.		
	7	JP 11-012326	01-19-1999	Fujitsu Ltd.		Abstract
	8	JP 2000-321771	11-24-2000			
	9	JP 2001-002735	01-09-2001	Mitsubishi Rayon Co. Ltd		Abstract
	10	JP 04-039665	02-10-1992	Fujitsu Ltd.		Abstract
	11	JP 05-346668	12-27-1993	Fujitsu Ltd		Abstract
	12	JP 09-073173	03-18-1997	Fujitsu Ltd.		Abstract
	13	JP 09-090637	04-04-1997	Fujitsu Ltd.		Abstract
	14	JP 10-161313	06-19-1998	Fujitsu Ltd.		Abstract
	15	JP 10-319595	12-04-1998	Fujitsu Ltd.		Abstract
	16	JP 2002-311587	10-23-2002			

NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹
	17	International Search Report from PCT priority application serial no. PCT/JP2004/008004.	
	18	Written Opinion from PCT priority application serial no. PCT/JP2004/008004.	

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Examiner Signature	Date Considered
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***Examiner:** Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

T¹ - Place a check mark in this area when an English language Translation is attached.